



APPENDIX A
"CLEAN" VERSION OF EACH PARAGRAPH/SECTION/CLAIM
37 C.F.R. § 1.121(b)(ii) AND (c)(i)

CLAIMS (with indication of amended or new):

Amended 1. An electronic device comprising:
a substrate;
a lower electrode layer on the substrate and comprising a material capable of
reactive-ion etching with a fluorine-based gas; and
an upper electrode layer on the lower electrode layer and comprising a material
capable of reactive-ion etching with a chlorine-based gas.